

WE CLAIM

1. A micro-electromechanical fluid ejection device that comprises
a substrate that incorporates drive circuitry;
nozzle chamber walls and a roof that are positioned on the substrate to define a
nozzle chamber with the roof defining a fluid ejection port in fluid communication with the
nozzle chamber;

10 a fluid-ejecting member that is operatively positioned with respect to the nozzle
chamber, the fluid-ejecting member being displaceable with respect to the substrate to eject
fluid from the fluid ejection port;

an actuator that is connected to the fluid-ejecting member and to the drive circuitry,
the actuator being displaceable upon receipt of an electrical signal from the drive circuitry
to displace the fluid-ejecting member and thus eject fluid from the fluid ejection port; and

a covering formation that is positioned on the substrate so that the substrate and the
covering formation define an air chamber, the actuator being positioned within the air
chamber.

2. A device as claimed in claim 1, which is the product of an integrated circuit
fabrication technique.

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3. A device as claimed in claim 2, in which the substrate includes a silicon wafer
substrate, a CMOS drive circuitry layer positioned on the silicon wafer substrate and an ink
passivation layer positioned on the CMOS drive circuitry layer.

4. A device as claimed in claim 3, in which each fluid-ejecting member is positioned
in its respective nozzle chamber and is displaceable towards and away from the fluid
ejection port.

30 5. A device as claimed in claim 3, in which each nozzle arrangement includes a work-
transmitting structure that is displaceable with respect to the substrate and is connected to
the fluid-ejecting member so that displacement of the work-transmitting structure results in
displacement of the fluid-ejecting member, the actuator being connected to the work-
transmitting structure to displace the work-transmitting structure.

6. A device as claimed in claim 5, in which the roof, the work-transmitting structure and the covering formation together define a protective structure that is positioned in a common plane.

7. A device as claimed in claim 3, in which a plurality of fluid inlet channels are defined through the substrate, with each fluid inlet channel opening into a respective nozzle chamber.

10 8. A device as claimed in claim 6, in which the roof, the work-transmitting structure and the covering formation are configured so that the protective structure is unitary.